NO. 8366

Docket No. 0756-2222

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Patent Application of		)	Art Unit: 2829
Shunpei YAMAZAKI et al.		)	Examiner: A Sakar
Serial No. 09/699,466 )			CERTIFIC
Filed:	October 31, 2000	)	I hereby certify that this certification The United States Postal States Mail in an envelope of P.O. Box 1450, Alexandria,
For:	METHOD FOR FABRICATING A	)	
	SEMICONDUCTOR DEVICE	)	

CERTIFICATE OF MAILING

certify that this correspondence is being deposited with ted States Postal Service with sufficient postage as First ail in an envelope addressed to: Commissioner for Patents, 1450, Alexandria, VA 22313-1450, on June 23, 2003.

in My tamper

## <u>AMENDMENT</u>

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated January 22, 2003, please amend the above-identified application as follows:

## IN THE CLAIMS:

## Please amend claims 1 and 35-45 as follows.

(Amended) A method for manufacturing a semiconductor device 1. comprising:

forming a semiconductor film on an insulating surface;

forming a semiconductor island having a tapered shape by patterning said semiconductor film, said tapered shape having an angle within a range of 20° to 50° between a side thereof and an underlying surface;

performing a plasma treatment to the semiconductor island;

forming a first gate insulating film over the semiconductor island wherein the first gate insulating film comprises silicon oxide;

forming a second gate insulating film over the first gate insulating film wherein the second gate insulating film comprises silicon oxide nitride;

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